

Radiation Tolerance of DEPFET Active Pixel Sensors

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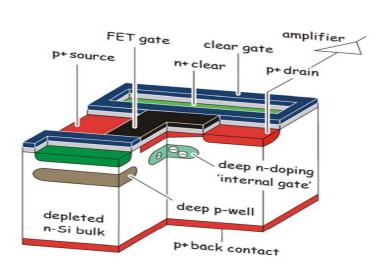
- DEPFET principle
- DEPFET as vertex detector for ILC
- Requirements with respect to radiation hardness
- Investigations of irradiated structures

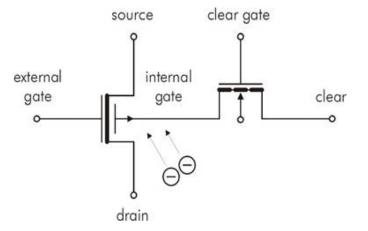
Stefan Rummel; MPI for Physics

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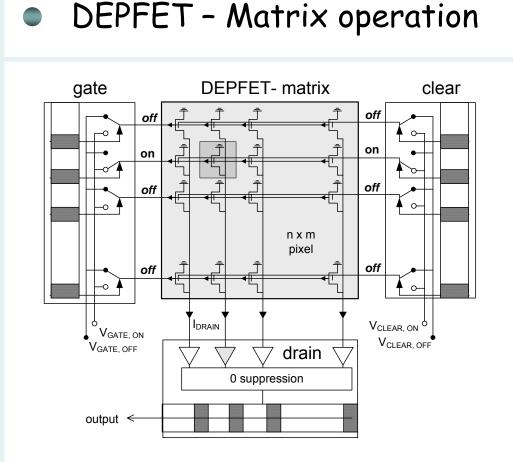
DEPFET - Depleted Field Effect Transistor

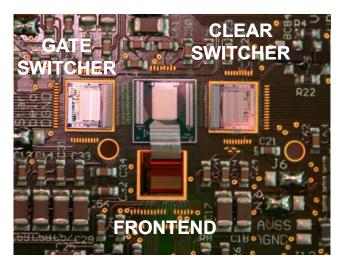
- Combination of detector grade silicon with first p-FET amplification stage in each pixel
- Potential minimum for electrons is created under the channel by sideward depletion and an additional **n-doping**
- Electrons in the "internal gate" modulate the transistor current
- Signal charge is removed via a clear contact
- Large sensitive volume due to fully depleted bulk
- Low noise caused by a small input capacitance and internal amplification
- Transistor can be **switched off** by external gate charge collection is then still active!





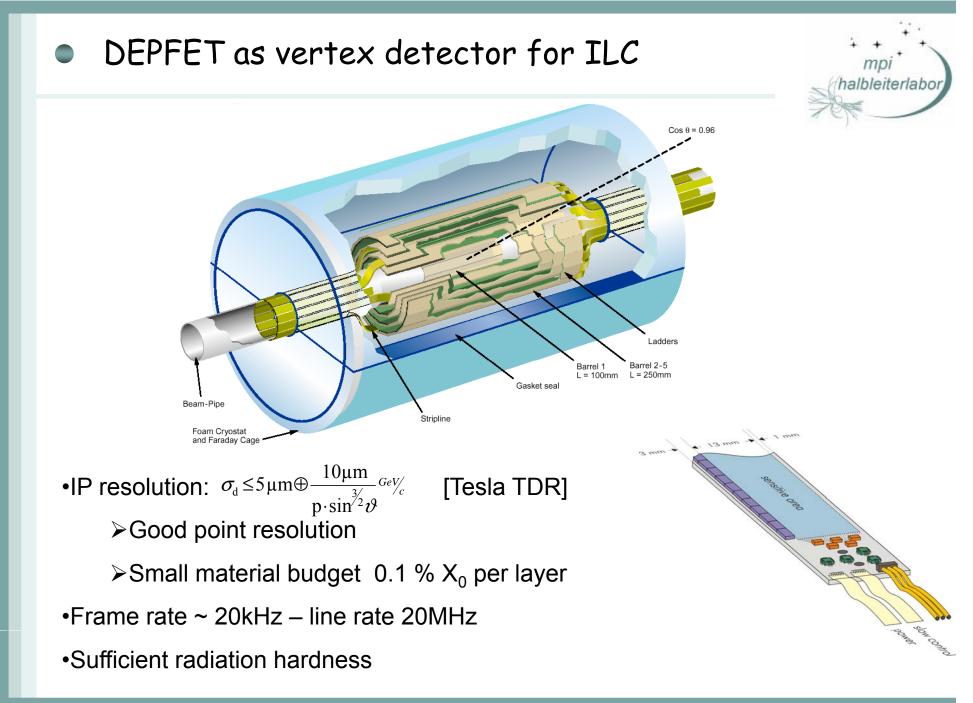






- Column parallel architecture for fast readout
- Row wise readout operation: Sample-Clear-Sample no charge transfer
- Low power dissipation only one row active while readout

halbleiterlabo

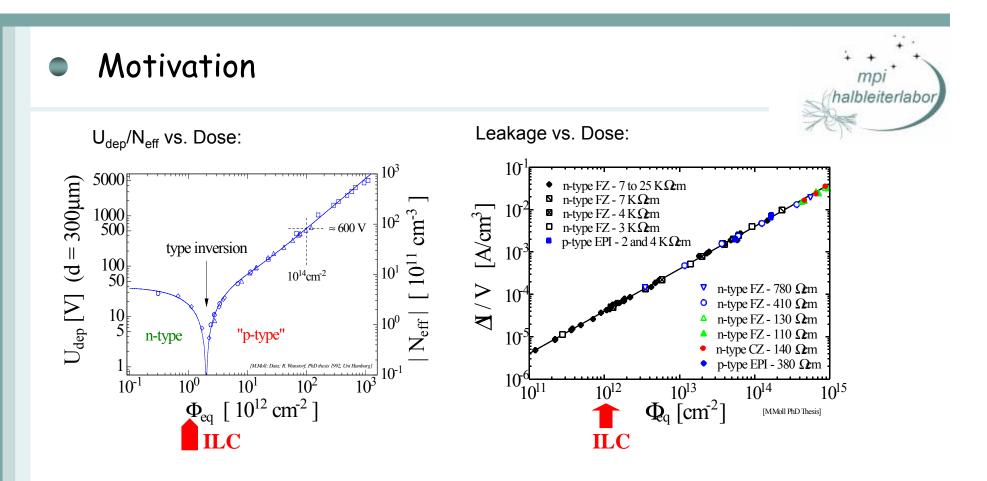






- •e from Beamstrahlung
- •n backscattered form the calorimeter
- •Total dose around 360krad in 10 years [LDC DOD]
- Moderate cooling with cold gas stream

Expected flux:	1.7*10 ¹² e/cm2/year	@ 10MeV [LDC DOD]
	10 ⁹ n/cm2/year	@ 1MeV n equiv. [LDC DOD]
∑ (e- + n)	8.5 * 10 ¹⁰ /cm ² /year	@ 1MeV n equiv. [LDC DOD]

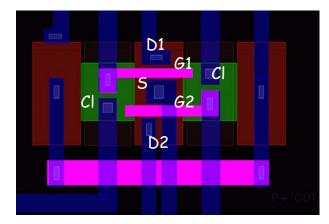


- Space charge sign inversion is not expected to be a problem
- BUT: Several remaining questions:
 - Noise contribution from leakage current? (50µs integration time)
 - What is the extend of the threshold voltage shift?
 - > Does the performance of the FET degrade under irradiation?

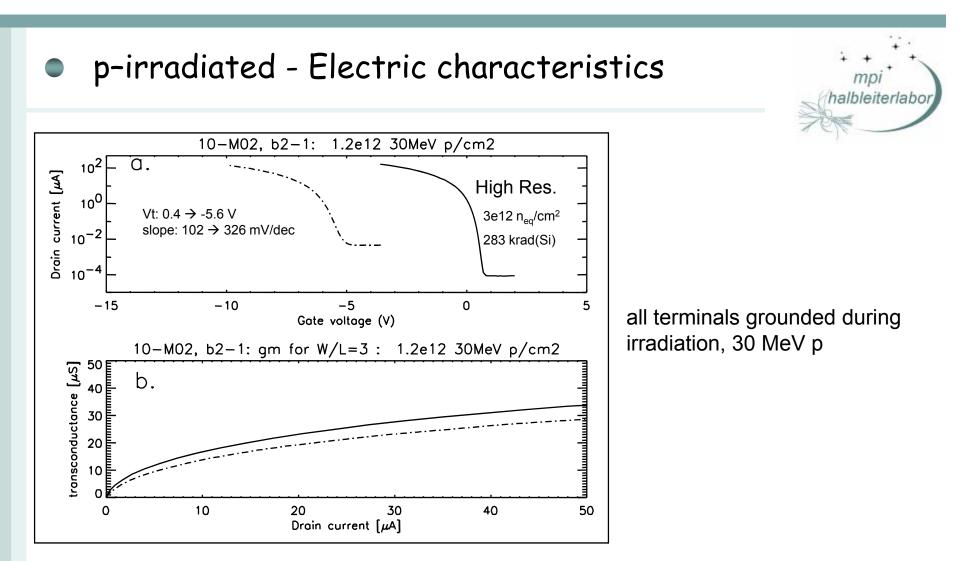


- •Single pixel structures with 6µm gate length
- •Current based readout
- •Characterization with respect to:
 - Electric characteristics (Vth, gm, gq)
 - Leakage current (NIEL)
 - Spectroscopic performance
 - Noise power density (1/f noise)

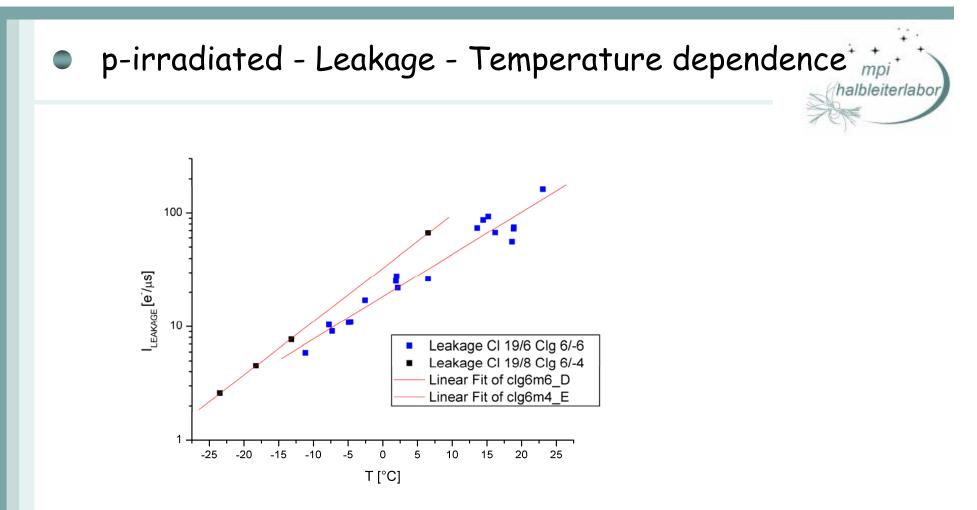




Туре	Protons @ 30MeV	Neutrons @ 1-20MeV	Gammas - Co60	
Dose	1.2 * 10 ¹² p/cm²	1.6 * 10 ¹¹ n/cm²	913kRad	
1MeV n equivalent	3*10 ¹²	2.4*10 ¹¹		
ILC – expectation [LDC DOD]	1MeV n equivalent: 8.5 * 10 ¹⁰ /cm²/year			
ILC operation	35 years	3 years		



- Threshold voltage shift small compared to the expectations for a dielectric exceeding 200nm
- Increase of sub threshold slope indicate a increase of 1/f-noise
- g_m is noticeably reduced by 15%

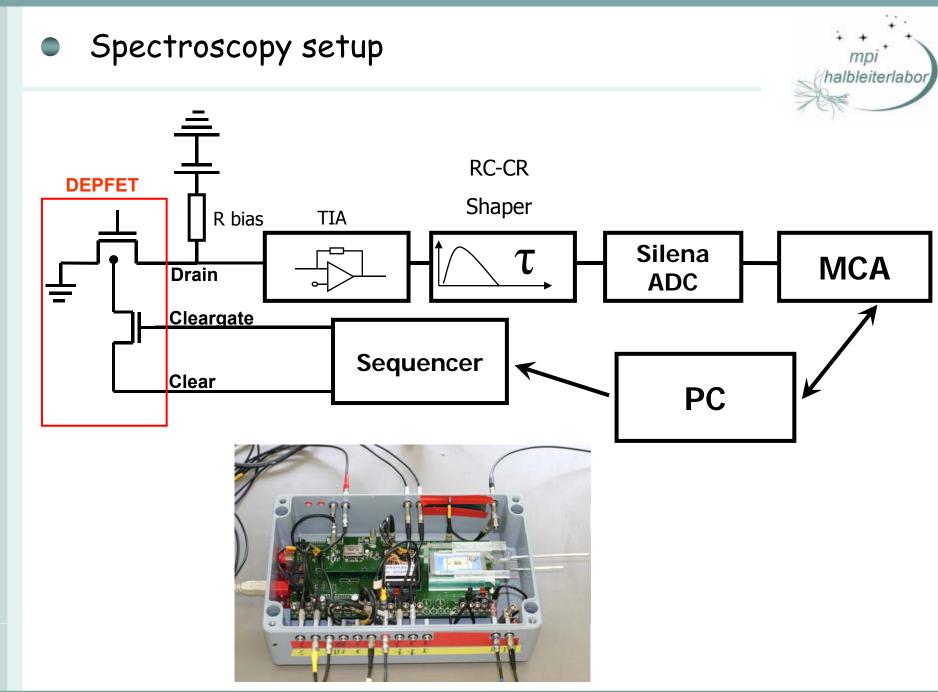


•Dependence on operation voltages -> additional contribution which is not bulk generated

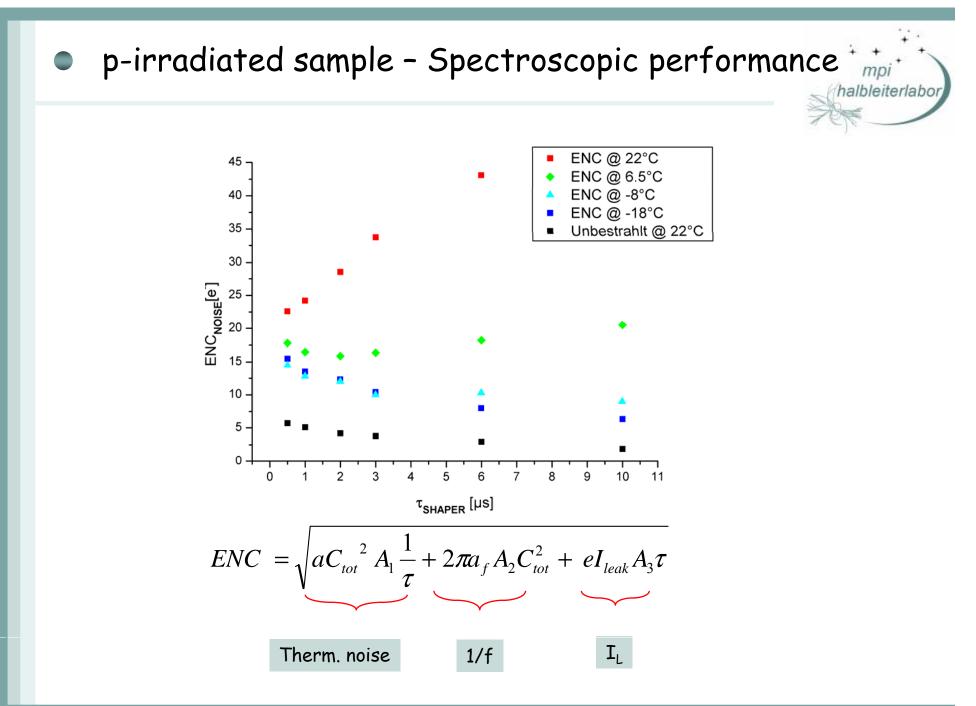
•Thick detector, bulk generated current will decrease with thickness

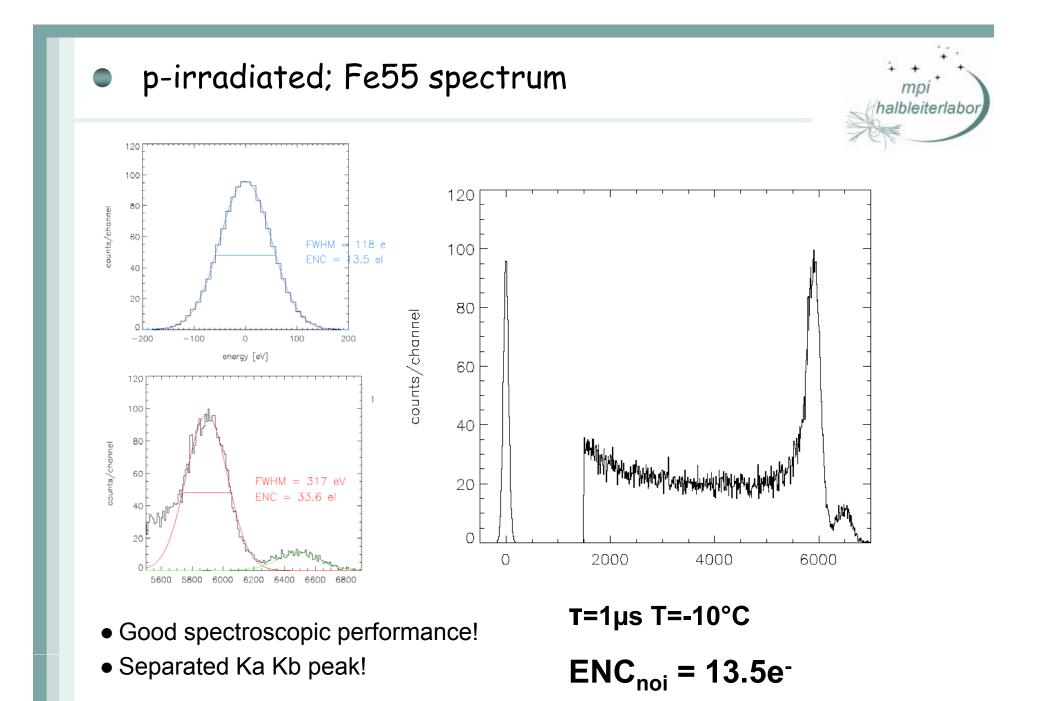
•At 0°C around 20e/µs! -> L=50µs -> 31e contribution to noise

•Irradiation far beyond 10 years of ILC operation



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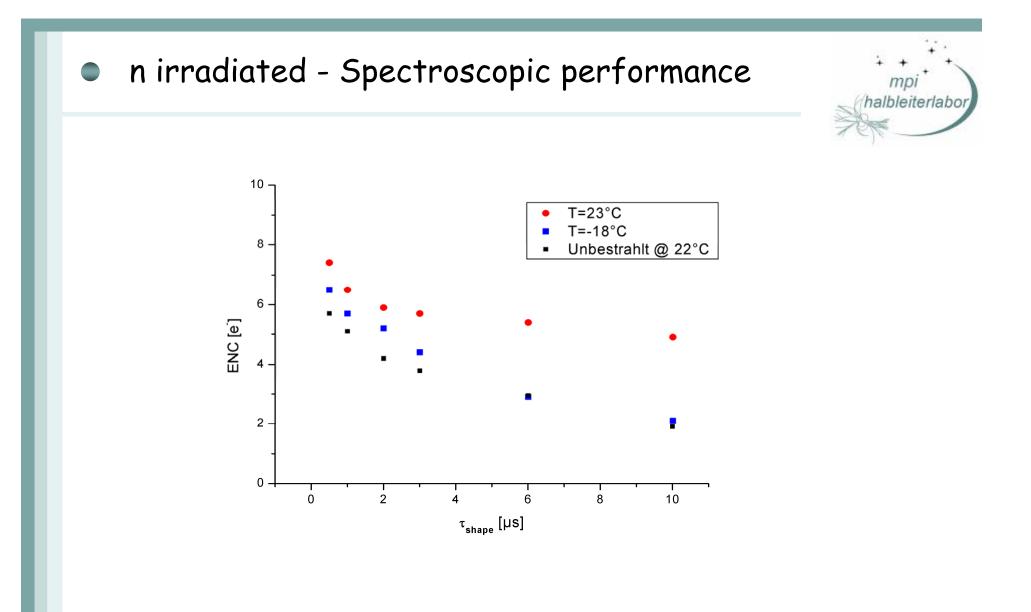


p - Irradiation - Summary

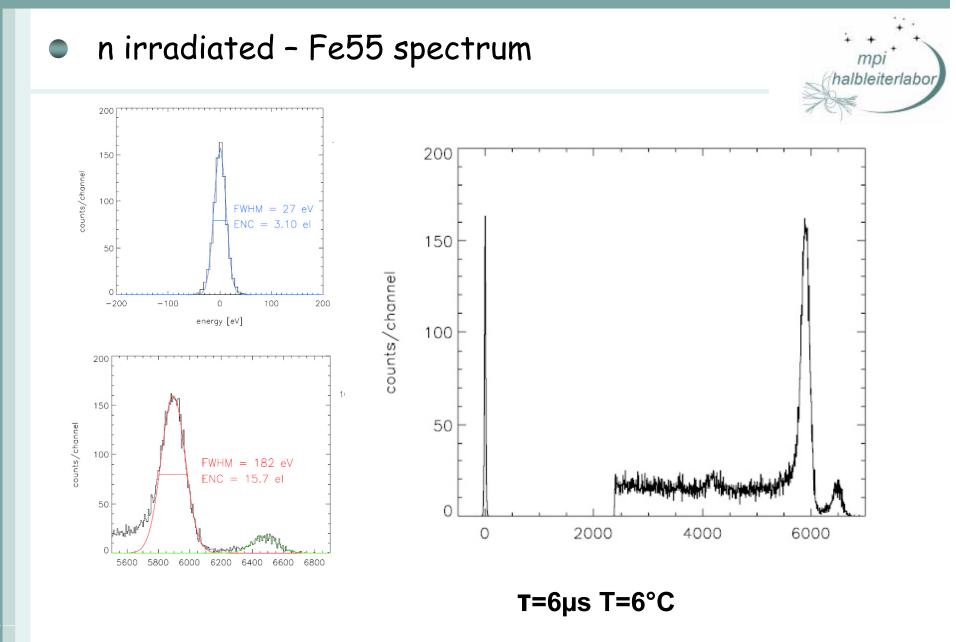


- DEPFET fully operable after $3*10^{12} n_{eq}/cm^2$
- Threshold voltage shift acceptable
- Gm slightly decreased by 15%
- Noise contribution due to leakage current is tolerable

n irradiated - Electrical characteristic halbleiterlabo 5-M05, a2-1: 1.6e11 n/cm2 10^{2} a. Drain current $[\mu A]$ 100 HE implant 10^{-2} Vt: -1.2 V 2..3e11 n_{eq}/cm² 10-4 slope: 96 \rightarrow 98 mV/dec 10 -2.0 -1.5 -1.0 -0.5 0.0 Gate voltage (V) 5-M05, a2-1: gm for W/L=3 : 1.6e11 n/cm2 50 transconductance $[\mu S]$ b. 40 Ē 30 Ē 20 Ē 10 0 0 10 20 30 40 50 Drain current $[\mu A]$ all terminals grounded during irradiation, 1-20 MeV neutrons (LBNL) • No thresholdvoltage shift observed! • No significant increase in subthreshold slope!



- Leakage around 8.9e/µs @ 23°C
- At low temperatures the performance is similar to unirradiated structures!

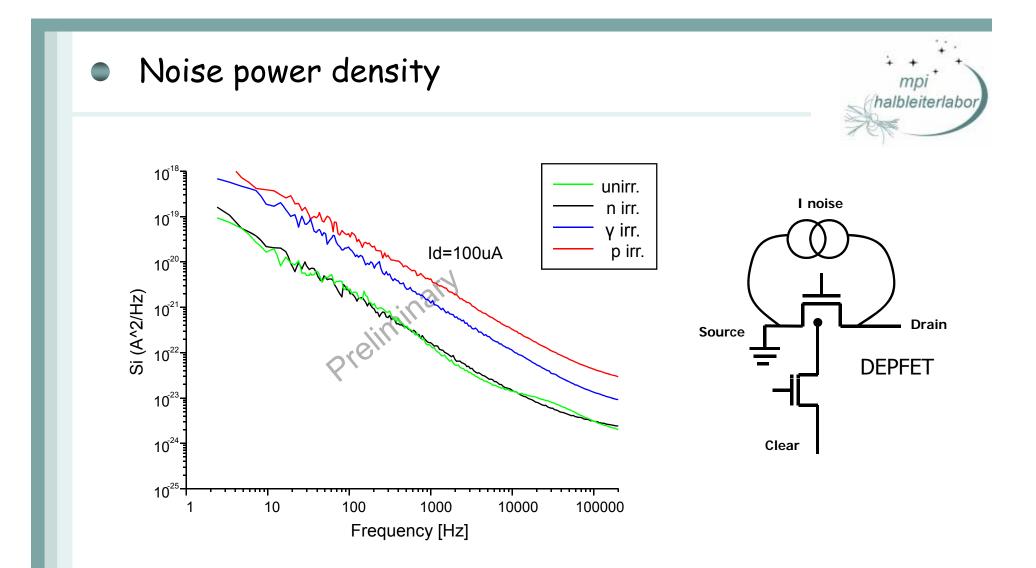


ENC_{noi} =3.1e⁻

n – Irradiation – Summary



- Transistor performance unchanged
- No interface damage observed
- Good spectroscopic performance

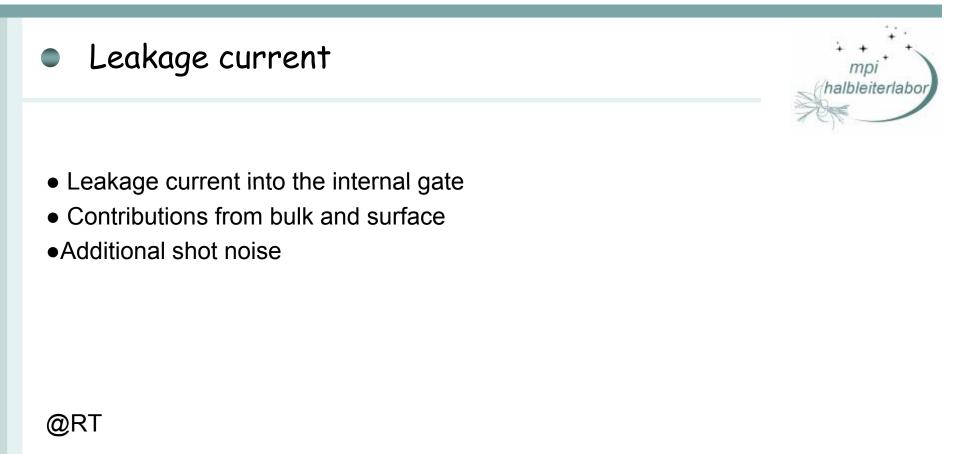


- Corner frequency increased
- Expectation from sub threshold slope are confirmed





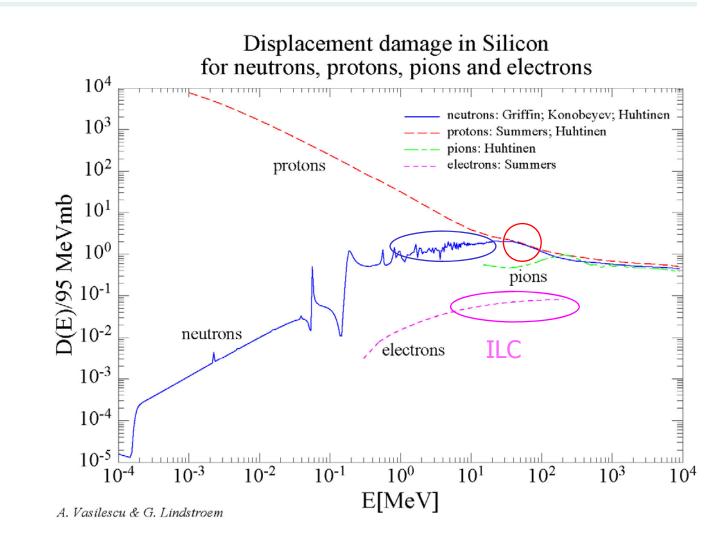
- •Irradiated structures are operable after irradiation
- •Threshold voltage shift is in an acceptable region
- •Both structures show good spectral resolution
- •Noise power density behaves as expected from sub threshold slope
- The DEPFET double pixel structure could be considered as radiation hard with respect to the ILC requirements



Unirradiated	Gamma	Neutron	Proton
Typ. 20fA	200fA	1.4pA	25.9pA







 Shaper measurement vs. CDS 			halbleiterlabor
	Continuous shaping (time invariant)	Time dependent shaping	
White noise	$\sqrt{\alpha \frac{2 kT}{g_m} C_{tot}^2 A_1 \frac{1}{\tau}}$	$\sqrt{4kT\frac{2}{3}\frac{g_m}{g_g^2}NBW}$	
1/f noise	$\sqrt{2\pi a_f C_{tot}^2 A_2}$	$\sqrt{a_f \frac{g_m^2}{g_q^2} 2\int_{0}^{\infty} \frac{1 - \cos(2\pi \tau x)}{x(1 + x^2)} dx}$	
Shot noise - leakage	$\sqrt{I_L A_3 \tau}$	$\sqrt{I_L T_{frame}}$	

ENC depends on:

- Shaping time
- Response function
- Frame time
- Bandwidth
- CDS time

•Both variants are sensitive to the same noise sources, but in different extend

Influence of the radiation



- NIEL (Non Ionizing Energy Loss)
 - Mainly damage to the bulk
- Ionizing Energy Loss (charged particles)
 - · Damages interface and bulk

• Macroscopic effects:

- Shift in threshold voltage
- Increase of leakage current bulk and interface
- Increase of 1/f noise
- Change in effective doping